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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/747,824		12/29/2003	Daniel C. Diana	INTEL16	6455	
6980	7590	02/23/2005		EXAM	EXAMINER	
TROUTMA				DANG, TRUNG Q		
		A PLAZA, SUITE 520		ART UNIT	PAPER NUMBER	
600 PEACH ATLANTA,		,		2823		

DATE MAILED: 02/23/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	
Office Action Summer.	10/747,824	DIANA ET AL.	
Office Action Summary	Examiner	Art Unit	
The MAN INC DATE of the	Trung Dang	2823	
Period for Reply	nication appears on the cover sheet w	ith the correspondence address	
A SHORTENED STATUTORY PERIOD F THE MAILING DATE OF THIS COMMUN - Extensions of time may be available under the provision after SIX (6) MONTHS from the mailing date of this com - If the period for reply specified above is less than thirty (- If NO period for reply is specified above, the maximum s - Failure to reply within the set or extended period for repl Any reply received by the Office later than three months earned patent term adjustment. See 37 CFR 1.704(b).	IICATION. s of 37 CFR 1.136(a). In no event, however, may a munication. 30) days, a reply within the statutory minimum of thi tatutory period will apply and will expire SIX (6) MOI y will, by statute, cause the application to become A	reply be timely filed ty (30) days will be considered timely. ITHS from the mailing date of this communicati BANDONED (35 U.S.C. § 133).	on.
Status			
3) Since this application is in condition	2b)⊠ This action is non-final.		is
Disposition of Claims			
4) ⊠ Claim(s) <u>1-25</u> is/are pending in the 4a) Of the above claim(s) is/a 5) ⊠ Claim(s) <u>1-9 and 22-25</u> is/are allow 6) ⊠ Claim(s) <u>10-15 and 18</u> is/are rejected 7) ⊠ Claim(s) <u>16,17 and 19-21</u> is/are obj 8) ☐ Claim(s) are subject to restrict the subject the subject the subject the subject the subject the	are withdrawn from consideration. ed. ed. ected to.		
Application Papers			
	e: a) accepted or b) objected to ection to the drawing(s) be held in abeyag the correction is required if the drawing	nce. See 37 CFR 1.85(a). (s) is objected to. See 37 CFR 1.121	(d).
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim a) All b) Some * c) None of: 1. Certified copies of the priority 2. Certified copies of the priority 3. Copies of the certified copies	o documents have been received. Or documents have been received in Arrive of the priority documents have been bonal Bureau (PCT Rule 17.2(a)).	opplication No received in this National Stage	
Attachment(s)			
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (in the state of the stat	PTO-948) Paper No	Summary (PTO-413) s)/Mail Date nformal Patent Application (PTO-152) 	

Application/Control Number: 10/747,824 Page 2

Art Unit: 2823

DETAILED ACTION

Claim Rejections - 35 USC § 103

1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 13-15, 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Johnson et al. (US 2002/0197844) in view of Gudesen (US 2003/0107067).

With reference to Figs. 9-10, Johnson teaches a ferroelectric die, comprising: a silicon (Si) substrate 10;

an oxide thermal insulation layer 20 on top of the Si substrate;

a first metal layer 22, 28 on top of the oxide layer;

a ferroelectric layer 30' on top of the first metal layer (Fig. 9 and para.[0044]);

an interlevel dielectric (ILD) layer 36' on top of the ferroelectric layer;

a second metal layer 40 having on top of the ILD layer; and

a via metal 99 plug passing through the ILD layer and the ferroelectric

layer to electrically connect the first metal layer 22, 28 to the second metal layer

40.

Note that the metal layer 99 is broadly interpreted as via metal plug because it is formed in the via.

Johnson differs from the claims in that while Johnson discloses layer

Application/Control Number: 10/747,824

Art Unit: 2823

30' is of ferroelectric material, the claims call for a ferroelectric polymer.

Gudesen teaches the advantages of ferroelectric polymer materials, for example, their dielectric properties allow their function as electrically insulating barrier materials as well as the possibility of applying them in global layers of extreme thickness down to few nanometers (para. [0032]).

It would have been obvious to one of ordinary skill in the art to modify the teaching of Johnson by selecting the ferroelectric polymer material for the ferroelectric layer 30' as suggested by Gudesen because of the benefits mentioned above.

As for claims 14 and 15, Fig. 10 depicts metal layer 99 has a step and the portion adjacent to the step is below the surface of the ILD 36'.

As for claim 18, metal layer 99 has a portion that is coplanar with the IDL layer 36'.

Claim Rejections - 35 USC § 112

2. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 10 –12 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The limitation "the activation solution" recited in claim 10 lacks antecedent basis. Claim 10 should depend on claim 5. Similarly, claim 11 should depend on claim 5 because the "metal plating solution" lacks antecedent basis.

Application/Control Number: 10/747,824 Page 4

Art Unit: 2823

The limitation "the open area in the photoresist" recited in claim 12 lacks antecedent basis.

Allowable Subject Matter

- 3. Claims 16-17 and 19-21 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- 4. Claims 1-9, 22-25 are allowed.
- 5. The following is an examiner's statement of reasons for allowance:

Independent claim 1 and its dependent claims are allowed over prior of record because the prior art of record does not teach or suggest the claimed step regarding an electroless plating process.

Independent claim 22 and its dependent claims are allowed over prior of record because the prior art of record does not teach or suggest the claimed structure regarding a plurality of metallization layers stacked on an oxide layer, wherein each metallization layer comprises elements as recited in the claim.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Trung Dang whose telephone number is 571-272-1857. The examiner can normally be reached on Mon-Friday 9:30am-6:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Trung Dang Primary Examiner Art Unit 2823

My Dang

Page 5

2/22/05